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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Si Yi LI et al.

Application No.: 09/820,695

Filed: March 30, 2001

For: METHOD OF PLASMA ETCHING
LOW-K DIELECTRIC MATERIALS

)
)
) Group Art Unit: 1746
)
) Examiner: Not Yet Assigned
)
) Confirmation No. 4162
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INFORMATION DISCLOSURE STATEMENT
TRANSMITTAL LETTER

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Enclosed is an Information Disclosure Statement and accompanying form PTO-1449 for the above-identified patent application.

- ☒ [X] No additional fee for submission of an IDS is required.
- ☐ [] The fee of \$180.00 (126) as set forth in 37 C.F.R. § 1.17(p) is also enclosed.
- ☐ [] A certification under 37 C.F.R. § 1.97(e) is also enclosed.
- ☐ [] A certification under 37 C.F.R. § 1.97(e), and the fee of \$180.00 (126) as set forth in 37 C.F.R. § 1.17(p) are also enclosed.
- ☐ [] Charge \$_____ to Deposit Account No. 02-4800 for the fee due.
- ☐ [] A check in the amount of \$_____ is enclosed for the fee due.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,
BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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Date: December 12, 2002

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Patent
Attorney's Docket No. 015290-500

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INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In accordance with the duty of disclosure as set forth in 37 C.F.R. § 1.56, Applicants hereby submit a PCT Search Report dated November 20, 2002 for a corresponding application. Pursuant to 37 C.F.R. § 1.98, a copy of each of the documents cited in the Search Report but not of record in the present application is enclosed.

U.S. Patent No. 6,114,250, Morey et al., issued September 5, 2000;
WO 00 67308A, published November 9, 2000;
WO 01 04707A, published January 18, 2001;
WO 02 03454A, published January 10, 2002; and
Patent Abstracts of Japan, Vol. 2000, No. 21, JP 2001 118825A,
published April 27, 2001.

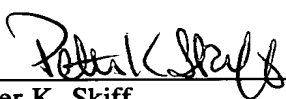
I, the undersigned, hereby state that each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart application and that this communication was not received by any individual designated in § 1.56(c) more than 30 (thirty) days prior to the filing of this Information Disclosure Statement.

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To assist the Examiner, the documents are listed on the attached form PTO-1449. It is respectfully requested that an Examiner initialed copy of this form be returned to the undersigned.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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